

684.3067

PATENT APPLICATION

#5a
NEAL

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
: Examiner: Unassigned
ICHIRO TANAKA)
: Group Art Unit: Unassigned
Application Based on)
JP 250853/1999 :
:)
Filed: Herewith :
:)
For: TWO-DIMENSIONAL PHASE :
ELEMENT AND METHOD OF)
MANUFACTURING THE SAME : August 31, 2000

Commissioner for Patents
Washington, D.C. 20231

PRELIMINARY AMENDMENT

Sir:

Prior to examination on the merits of the above-identified application, please amend the application as follows.

In the Claims:

Please amend claims 2-4, 6-13 and 15 as follows:

a1 SUB B1 2. (Amended) A method of manufacturing a two-dimensional phase type element[,] comprising the steps of:
forming[, on a substrate,] a first etching mask in
a checkered pattern on a substrate; and